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PATENT

IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

Applicants: Yi-Fan Chen, Examiner: Huynh, Andy
5 Chi-King Pu,
Shou-Kong Fan

Filing Date: 04/18/01 Art Unit: 2818

Serial No.: 09/836,258 Docket No.: NAUP0280USA

10 Title: BYPASS CIRCUITS FOR REDUCING PLASMA DAMAGE

To: Assistant Commissioner for Patents
Washington, D.C. 20231

15 Subject: Response to the Office action dated 01/24/02

Dear Sir:

AMENDMENT

20

In response to the Office action identified above,
please amend the above-identified application as follows:

In the claims:

25

Cancel claims 7-14.